



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Patent Application

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Case **46-19-123**

Serial No. **09/516004** Group Art Unit **2811**

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Examiner **O. Nadav**

Title **Selective Laser Anneal On Semiconductor Material**

**ASSISTANT COMMISSIONER FOR PATENTS**  
**WASHINGTON, D. C. 20231**

**SIR:**

**ELECTION OF CLAIMS**

In response to the Official Action of March 7, 2001, Applicant hereby elects to prosecute Group I, Claims 6-11, with traverse. It is submitted that the inventions of Groups I and II are not distinct because the process of Group II does not require providing dopant to spaced apart regions after forming a FET gate structure. Process claims are not limited to the sequence of recitation unless expressly stated in the claims. Withdrawal of the restriction requirement is required.

Respectfully Submitted,

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Dated: 4/6/01

I hereby certify that this correspondence is being deposited with the United States Postal Service as first class mail in an envelope addressed to: Commissioner of Patents and Trademarks Washington, D.C. 20231 on 4-9-01

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